## What is claimed is:

- 1. A semiconductor package for a micro-machined semiconductor device, comprising:
  - a) a substrate having a first surface and a second surface, the micro-machined semiconductor device located adjacent the first surface;
  - a plurality of vias, extending through the substrate between the first and second surfaces;
  - c) an electrical connection located between the vias and the micro-machined semiconductor device for electrically connecting the vias to the semiconductor device;
  - d) a seal, located between the micro-machined semiconductor device and the first surface for hermetically sealing the micro-machined semiconductor device;
  - e) a rigid support located between the micro-machined semiconductor device and the first surface for supporting the micro-machined semiconductor device during assembly; and
  - f) a plurality of solder spheres mounted to the second surface and electrically connected to the vias.

- 2. The semiconductor package according to claim 1, wherein the electrical connection includes:
  - a) a first pad located on the micro-machined semiconductor device; and
  - b) a second pad located on the first surface; and
  - c) a solder joint connected between the first and second pad.
- 3. The semiconductor package according to claim 1, wherein the substrate is a low temperature co-fired ceramic.
- 4. The semiconductor package according to claim 1, wherein the seal is a ring of solder located adjacent an outer perimeter of the substrate.
- 5. The semiconductor package according to claim 1, wherein the rigid support is attached to the first surface.
- 6. The semiconductor package according to claim 5, wherein the rigid support is gold.
- 7. The semiconductor package according to claim 5, wherein the rigid support is an alloy of gold and palladium.

- 8. The semiconductor package according to claim 5, wherein the rigid support is ultrasonically deposited.
- 9. The semiconductor package according to claim 3, wherein the substrate has a plurality of layers.
- 10. The semiconductor package according to claim 10, wherein a plurality of circuit lines are located on the layers, the circuit lines connected between the vias.
- 11. The semiconductor package according to claim 1, wherein a ball pad is attached to the second surface, the solder sphere attached to the ball pad.
- 12. The semiconductor package according to claim 11, wherein the solder sphere is attached to the ball pad by a reflowed solder paste.

- 13. A semiconductor package for a micro-machined semiconductor device comprising:
  - a) a low temperature co-fired ceramic substrate having a plurality of layers, the substrate having a top and a bottom surface;
  - b) a plurality of vias, extending between the layers;
  - c) a plurality of solder spheres, located on the bottom surface and electrically connected to the vias;
  - d) a plurality of rigid supports, attached to the top surface;
  - e) a seal located between the micro-machined semiconductor device and the top surface, the seal hermetically sealing the micro-machined semiconductor device;
  - f) the micro-machined semiconductor device spaced from the top surface by the rigid supports such that a movable portion of the micro-machined semiconductor device is unconstrained for movement; and
  - g) an electrical connection located between the vias and the micro-machined semiconductor device for electrically connecting the vias to the semiconductor device.

- 14. The semiconductor package according to claim 13, wherein the electrical connection includes:
- a) a first pad located on the micro-machined semiconductor device; and
- b) a second pad located on the top surface; and
- c) a solder joint connected between the first and second pad.
- 15. The semiconductor package according to claim 13, wherein the seal is a ring of solder located adjacent an outer perimeter of the substrate.
- 16. The semiconductor package according to claim 13, wherein the rigid support is gold.
- 17. The semiconductor package according to claim 13, wherein the rigid support is an alloy of gold and palladium.
- 18. The semiconductor package according to claim 13, wherein the rigid support is ultrasonically deposited.
- 19. The semiconductor package according to claim 13, wherein a plurality of circuit lines are located on the layers, the circuit lines connected between the vias.

- 20. The semiconductor package according to claim 13, wherein a ball pad is attached to the bottom surface, the solder sphere attached to the ball pad.
- 21. The semiconductor package according to claim 13, wherein the solder sphere is attached to the ball pad by a reflowed solder paste.

- 22. A method of making a semiconductor package comprising the steps of:
  - a) punching vias in at least two low temperature co-fired ceramic layers;
  - b) filling the vias with a conductor;
  - c) screen printing conductor lines on the layers;
  - d) screen printing a seal ring and a plurality of pads on one of the layers;
  - e) screen printing a plurality of ball pads on one of the layers;
  - f) stacking the layers;
  - g) laminating under pressure the layers into a substrate;
  - h) firing the substrate in an oven;
  - i) depositing a rigid support on the substrate;
  - j) screening a first solder paste onto the seal ring and the pads;
  - k) placing a micro-machined semiconductor device onto the substrate;
  - I) reflowing the first solder paste in an oven such that the micro-machined semiconductor device is attached to the substrate;
  - m) screening a second solder paste onto the ball pads;
  - n) placing a plurality of solder spheres onto the ball pads; and
  - o) reflowing the second solder paste in an oven such that the solder spheres are attached to the ball pads.
- 23. The method according to claim 22, wherein the rigid support is an ultrasonically deposited metal.

- 24. The method according to claim 22, wherein the metal is chosen from the group consisting of:
  - a) gold; and
  - b) an alloy of gold and palladium.